

RADIATION-SENSITIVE COMPOSITION CONTAINING A RESOLE
RESIN, A NOVOLAC RESIN, AN INFRARED ABSORBER AND A
TRIAZINE AND USE THEREOF IN
LITHOGRAPHIC PRINTING PLATES

5

ABSTRACT OF THE DISCLOSURE

A radiation-sensitive composition especially adapted to prepare a lithographic printing plate that is sensitive to both ultraviolet and infrared radiation and capable of functioning in either a positive-working or negative-working manner is comprised of (1) a resole resin, (2) a novolac resin, (3) a haloalkyl-substituted s-triazine and (4) an infrared absorber. The solubility of the composition in aqueous alkaline developing solution is both reduced in exposed areas and increased in unexposed areas by the steps of imagewise exposure to activating radiation and heating.